



# Workshop on **SPS** and **HPHT** sintering

## Workshop Programme

10<sup>th</sup> May 2024

Łukasiewicz – Krakow Institute of Technology, 37a Wroclawska St., 30-011 Kraków, Poland

09:00 09:40	Registration	
09:40 09:50	Workshop opening	Professor <b>Katarzyna M. Marzec</b> - Director of Łukasiewicz Research Network – Krakow Institute of Technology
09:50 10:10	Presentation of the technological possibilities of the Sintering Technology Center	Professor <b>Piotr Klimczyk</b> - Łukasiewicz Research Network – Krakow Institute of Technology
10:10-11:10	Invited speeches	
10:10 10:40	Professor <b>Lucyna Jaworska</b> – AGH University of Krakow <i>High-pressure phases in sintered materials based on zirconium and their impact on properties</i>	
10:40 11:10	Professor <b>Dariusz Garbiec</b> – Łukasiewicz – Poznań Institute of Technology <i>Overview of tools for spark plasma sintering</i>	
11:10 11:30	Coffee break	
11:30 11:45	Professor <b>Anatoli I. Popov, Marina Konuhova</b> , PhD Eng. - Institute of Solid State Physics University of Latvia <i>Functional Ceramics for Fusion Application</i>	
11:45 12:00	<b>Anna Kopeć-Surzyn</b> , MSc. Eng. - AGH University of Krakow <i>High-entropy alloys manufactured using the SPS method</i>	
12:00 12:15	<b>Maria Wiśniewska</b> , MSc. Eng. - Łukasiewicz – Poznań Institute of Technology <i>Complex-shaped ceramic matrix composites manufactured by spark plasma sintering</i>	
12:15 12:30	<b>Jakub Wiśniewski</b> , MSc. Eng. - Łukasiewicz – Poznań Institute of Technology <i>BTC composites for cutting operations obtained from WC-Ti powders by HEBM/SPS technology</i>	
12:30 12:45	<b>Wiktoria Krzyżaniak</b> , MSc. Eng. - Łukasiewicz – Poznań Institute of Technology <i>Application of FAST/SPS in the production of components for potassium-ion batteries</i>	
12:45 13:00	<b>Bohdan Sadovyi</b> . PhD Eng. - Institute of High Pressure Physics, Polish Academy of Sciences <i>High-pressure studies of nitride semiconductors: achievements and prospects</i>	
13:00 13:40	Lunch	
13:40 16:00	Presentation of sintering equipment and workshops on devices	